

Published online: 27 November 2018

OPEN Author Correction: Nanometrescale pattern formation on the surface of a photochromic crystal by optical near-field induced photoisomerization

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Correction to: Scientific Reports https://doi.org/10.1038/s41598-018-32862-9, published online 27 September

In Figure 3C, the horizontal axis is incorrectly labelled as 'Position (µm)'. This should read 'Position (nm)'. The correct Figure 3C appears below as Figure 1.

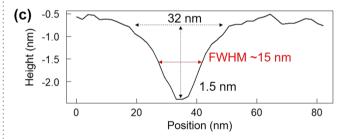


Figure 1. Local photoisomerization in a slightly coloured photochromic crystal. (c) Line profile obtained along the white line in (**b**).

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